L# ANSWER 36 OF 419 CAPLUS COPYRIGHT 2002 ACS

AN 2001:17838 CAPLUS

DN 134:87905

TI Method for preparation of high-purity pyrrolidone compounds

IN Nishida, Mitsuhiro; Ichiki, Tatsumi

PA Tonen Chemical Corp., Japan

-----

SO Jpn. Kokai Tokkyo Koho, 6 pp.

CODEN: JKXXAF

PATENT NO. KIND DATE

APPLICATION NO. DATE

PI JP 2001002638 A2 20010109 JP 1999-173074 19990618

AB The compds., e.g., N-methyl-2-pyrrolidone, useful as solvents and for industrial degreasing, defluxing application, etc., are manufd. by heating .gamma.-butyrolactone with NH3 or an amine compd. in the presence of water as usual, then feeding the mixt. (M) to a distn. tower, distg. in such a way that the residence time of the M at tower bottom maintained at 90-200.degree. is .apprx.10 min to 2 h while removing from the tower head a low-melting fraction contg. water and unreacted amine, from the towel bottom pyrrolidone compd. at 2-15% of introduced materials and from a side line the remaining pyrrolidone compd. The control of towel bottom temp. and residence time is essential for the improvement of product purity.

IC ICM C07D207-263

ICS B01D003-00; C07D207-267

DT Patent

LA Japanese